

Title (en)

Device and method for cleaning mostly level surfaces

Title (de)

Vorrichtung und Verfahren zum Reinigen weitgehend ebener Flächen

Title (fr)

Dispositif et procédé destinés à nettoyer des surfaces principalement planes

Publication

EP 1972246 B1 20100616 (DE)

Application

EP 08001327 A 20080124

Priority

DE 102007013343 A 20070320

Abstract (en)

[origin: EP1972246A1] The device has a housing (1) comprising a wiper blade (4) on a side, and a wiper block (3) for simultaneous supplying to a surface (7) to be cleaned. A side skirt (5) is provided on the housing, and laterally closes a space between the surface and the housing, and the wiper blade and the wiper block. The housing covers the wiper blade up to its front edge (8), and forms a guide edge (6), which pushes the wiper blade over its entire length against the surface to be cleaned. An independent claim is also included for a method for cleaning a level surface i.e. window.

IPC 8 full level

A47L 1/06 (2006.01)

CPC (source: EP)

A47L 1/06 (2013.01)

Cited by

AT15667U1; AT15667U8; CN113693485A; WO2016071135A1

Designated contracting state (EPC)

AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MT NL NO PL PT RO SE SI SK TR

DOCDB simple family (publication)

EP 1972246 A1 20080924; EP 1972246 B1 20100616; AT E471101 T1 20100715; DE 102007013343 A1 20080925; DE 102007013343 B4 20090226; DE 502008000784 D1 20100729

DOCDB simple family (application)

EP 08001327 A 20080124; AT 08001327 T 20080124; DE 102007013343 A 20070320; DE 502008000784 T 20080124